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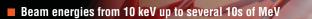
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## **Dr. John Bradley** University of Hawaii

Commercial NCM Cathode Material for Li-Ion Batteries. Atomic EDS map. Overlay shows O (red), Ni (blue), Mn (green).

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Dr. Miguel Jose Yacaman University of Texas, San Antonio Sample provided by Tour Lab, Rice University Chiral Nanotube with parameters n=10 and m=4 (simulated and experimental).

**Dr. Moon Kim** University of Texas, Dallas STEM HAADF image of transferred MoS<sub>2</sub>, showing Mo and S atom positions and their 2H stacking sequence.

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Focused ion beam technology and applications. Focused ion beam (FIB) microscopes coupled with a scanning electron microscope (SEM) offer the opportunity for novel sample imaging, sectioning, specimen preparation, three-dimensional nano- to macroscale tomography, and high resolution rapid prototyping. The articles in this issue of MRS Bulletin feature the state of the art in FIB technology and its applications

in materials research, providing insights into future potential for materials characterization and processing using FIBs. The cover image shows a three-dimensional view of FIB-patterned silicon milled for a microfluidic serpentine mixer application. Image courtesy of the American Vacuum Society. See the technical theme that begins on page 317.

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